# Silicon crystals for steering of highintensity particle beams at ultra-high energy accelerators

## CRYSTALS TECHNOLOGY AT INFN



Collimation
Beam steering
Innovative radiation sources
Pair production studies
Innovative detectors

Beam steering Innovative radiation sources Pair production studies Beam steering Innovative radiation sources Pair production studies CRYSBEAM SELDOM

### INFN COMPETENCIES

#### INFN has competencies related to

- Development of innovative ideas and research activities
   (connected to channeling and related effects)
- Crystals manufacturing and characterization
- Holders manufacturing and characterization
- Goniometry
- Trackers and detectors
- Data analysis
- Design of setups for channeling experiments

INFN is a scientific agency encompassing a full set of competencies related to studies of coherent effects between charged particle beams and crystals.

#### INFN INFRASTRUCTURE

Laboratory fully equipped for silicon micro and nanomachining ISO4 certified clean room (130 m<sup>2</sup>)

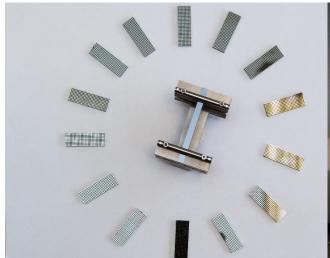
High-resolution x-ray diffraction
Dicing and polishing equipment
White light and Fizeau inteferferometers



## INFN INFRASTRUCTURE

Laboratory fully equipped for silicon micro and nanomachining

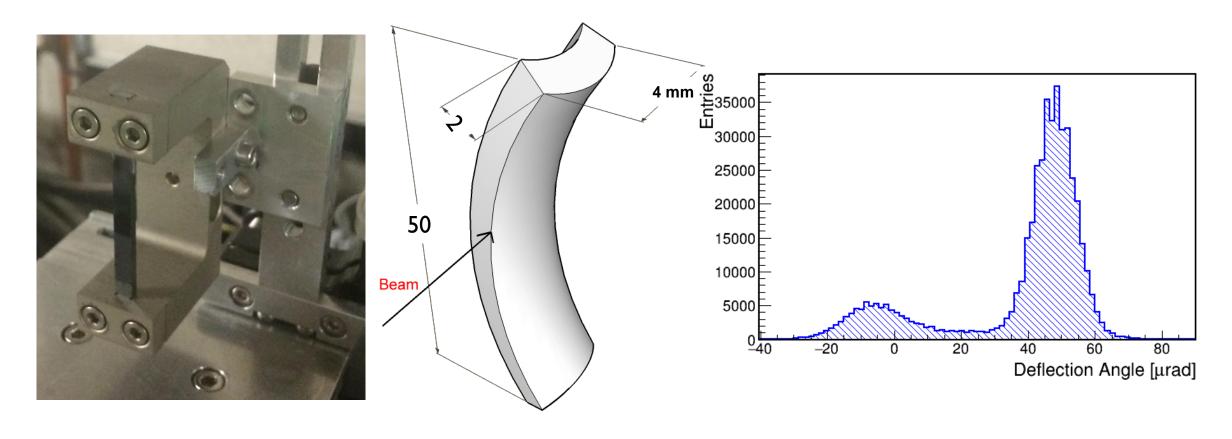
Fotolitography
Equipment for silicon chemical etching
Nanoimpringing





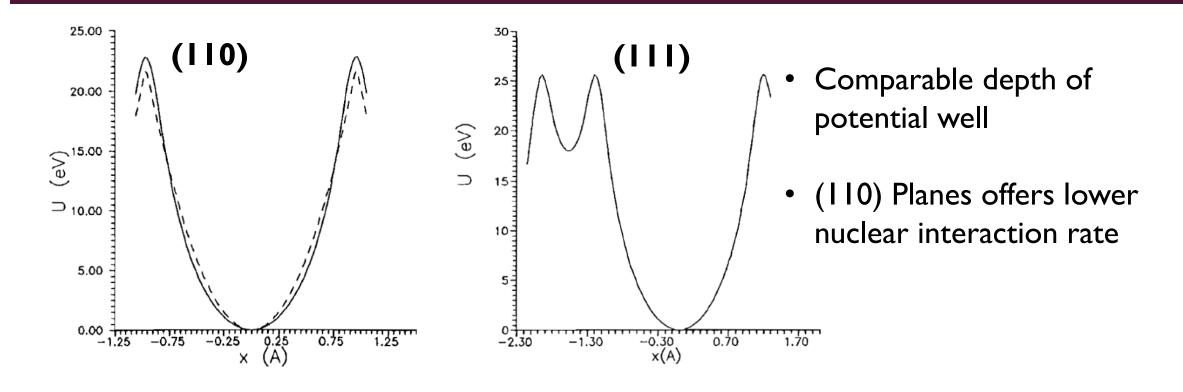


## STRIP CRYSTALS FOR THE LHC



A primary bending is mechanically imposed along the 50 mm size. As a result, «anticlastic bending» manifests along the 4 mm size.

### CHOICE OF CRYSTALLINE PLANES



See also W. Scandale et al., Eur. Phys. J. C (2018) 78:505

#### BRIEF RECAP ABOUT CRYSTALS MANUFACTURING

- 2006 Manufacturing based on mechanical dicing followed by chemical etching
- 2007 Manufacturing based on purely chemical methods
- 2014 Manufacturing of low-miscut crystals (<10 urad)
- 2018 Manufacturing based on mechanical dicing followed by chemical etching and polishing of surface entry face

  Manufacturing of ultra low-miscut crystals (<1 urad)

#### CRYSTAL MANUFACTURING – AFM AND HRTEM –

High-quality surfaces achieved via anisotropic chemical etching

**Lateral surface (AFM) Entry surface (High Resolution** transmission electron microscopy). Zero nm amorphous layer **Sub-nm roughness** achieved (0.2 nm)

#### BRIEF RECAPABOUT HOLDERS MANUFACTURING

2006 First holders version (in collaboration with IHEP), made of Al7075

2007 FEM-assisted optimization of holder geometry

2008 First prototypes of pre-shaped holders (aluminum)

2013 Request for holders with the following specs:

weight<90 g
UHV compatible (bakeable)
electron cloud compatible

About 90 commercial alloys, most common is «titanium grade 5» (90% Ti 6% Al 4% V)

2014 First generation of titanium grade 5 holders  $\rightarrow$  not compatible with bake-out

2018 Pre-shaped titanium grade 5 holders now fits LHC requirements

Thickness along the beam: 4.0±0.1 mm

Height < 55 mm.

Weight < 150 g

Channeling plane: (110)

Channeling axis: <111> or <110>

Miscut for axial channeling: 0±18 mrad

Miscut for planar channeling:  $< 10 \mu rad$ .

Torsion: < I μrad/mm

Bending angle: 47.5-52.5 µrad

Dislocation density < 1 cm<sup>2</sup>

#### Bake out

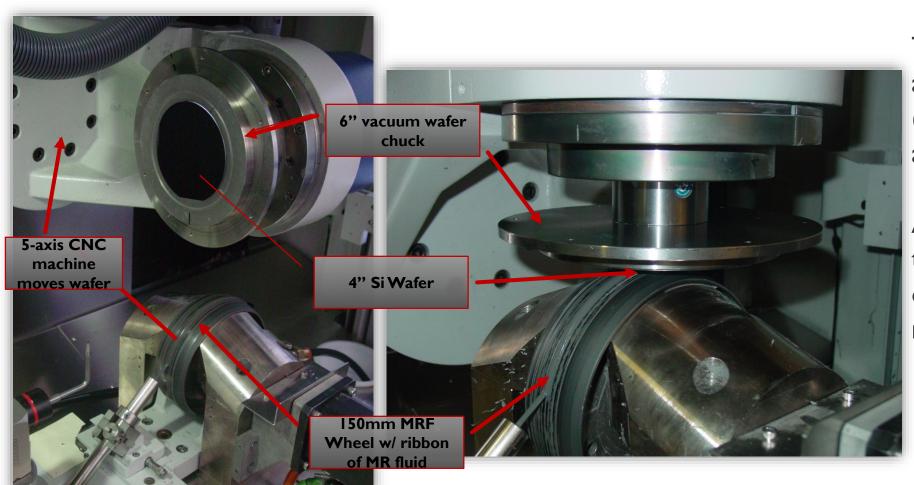
- Bake out temperature= 250°C
- heating ramp= 50°C/h
  - Bake out time =48h00
  - Number of thermal cycles: 3 at least
- Maximum allowed total outgassing after each bake out: I\*10<sup>-7</sup> mbar·I·s<sup>-1</sup>

The compliance of the mechanical properties of the crystal assemblies to the specifications of Table I, in particular the bending angle, must be assessed after at least 3 thermal cycles.

#### CHALLENGING ASPECTS

- ✓ Planar miscut: < 10 µrad → MRF finishing</p>
- ✓ Torsion: < I µrad/mm  $\rightarrow$  ultra precise machining and assembly.
- ✓ Bending angle: 47.5-52.5  $\mu$ rad → ultra precise machining and assembly.
- ✓ Dislocation density < I cm² → standard for microelectronics is I order of magnitude higher→ purchase of large quantity of silicon wafers and selection of the best ones.

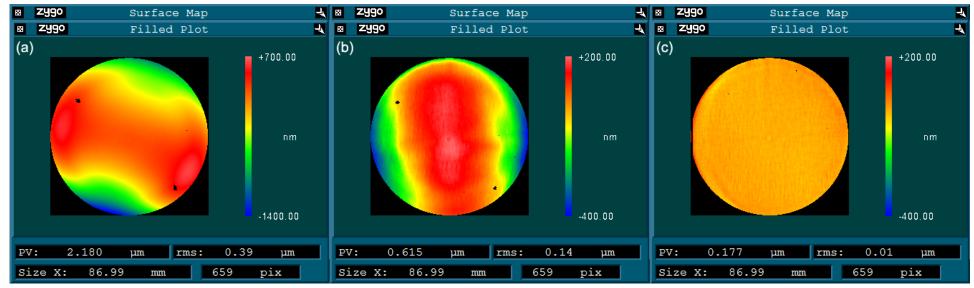
#### MRF FINISHING



Technique developed for astronomy applications (glasses and ceramics, i.e. amorphous materials)

After a 2 years R&D the tecnique was adapted to operate on crystalline materials.

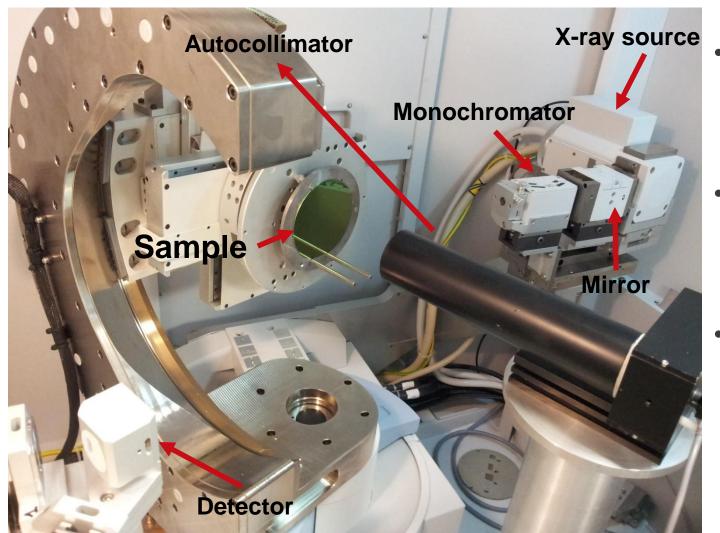
#### MRF FINISHING



Starting surface PV 2.18 um RMS 0.39 um Surface after first treatment PV 0.615 um RMS 0.14 um Final surface PV 0.177 um RMS 0.01 um

- MRF is a deterministic polishing process
- Does not induce any lattice damage
- Miscut < 1 urad</li>

#### MISCUT REDUCTION



 High resolution x-ray diffractometer (PANALYTICAL)

 Miscut: angle between optical surface and atomic planes

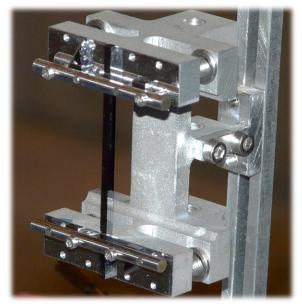
Requested miscut < 10 μad.</li>

#### RECENTLY DEVELOPED CRYSTALS

- Developed «pre-shaped» holders made of titanium grade 2 and grade 5.
- High-resolution x-ray diffraction characterizations: analysis of correlation
- Investigated thermal stability of holders+crystal assembly.
- Crystals for the LHC



#### PRE-SHAPED HOLDERS



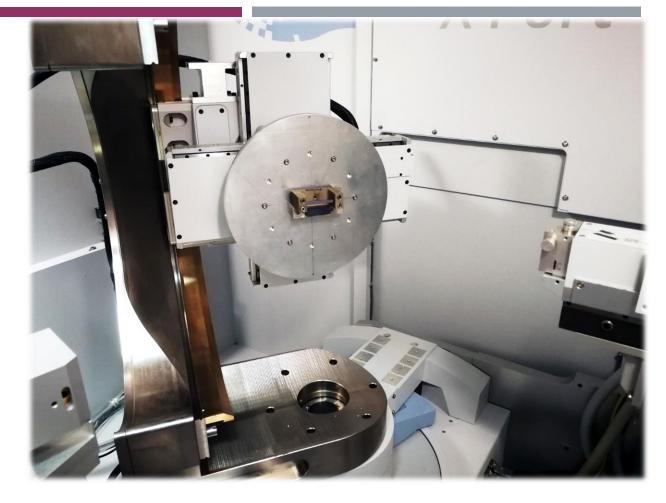
A pre-shaped holder manufactured in 2011 for UA9. Holder was made from aluminium and torsion correction mechanism still used. Base for development of current holders.

- Ultra-high precision machining provides holders with crystal-supporting surfaces inclined at a proper angle to impart to the crystal the desired deformation.
  - At first step, the holders are manufactured with approaches typical of conventional precision mechanics.
  - selected holders are treated with super-finishing techniques to adjust surface inclinations.
- Approach already developed for crystals installed in the SPS and for studies of multiple-volume reflections (~2010÷2015)
- Design is now revisited:
  - holders made of titanium grade 2 and grade 5 (previous version was made of aluminium).
  - removed torsion-adjustment mechanism.

A pre-shaped holder for LHC. Holder is made of titanium. Flexure for torsion adjustment have been removed.



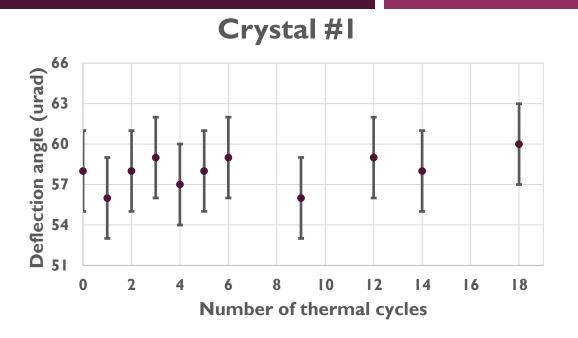
	Deflection	on angle (µrad)	
Crystal	High resolution x-ray diffraction	Channeling	Consistency
STF47	33±2	35±2	YES
STF48	144±2	142±2	YES
STF49	247±3	246±2	YES
STF50	142±5	143±2	YES
STF51	33±2	33±2	YES
STF70	56±2	55±2	YES
STF71	60±5	62±2	YES
STF99	119±3	120±2	YES
STF100	67±6	63±2	YES
STFIOI	170±6	165±2	YES
STF102	45±3	42±2	YES
STF103	52±5	54±2	YES
STF104	95±5	91±3	YES
STF105	49±3	50±2	YES
STF106	42±2	42±2	YES
STF107	56±2	56±2	YES
STF110	52±3	54±2	YES
STF110	56±10	62±2	YES
STF112	64±3	63±2	YES
STF113	46±3	45±1	YES
STF114	52±3	52±1	YES
STF117	53±3	50±1	YES
STF118	52±3	53±1	YES
STF119	54±3	52±1	YES
STF120	54±3	52±1	YES
STF121	48±3	48±1	YES
STF122	50±3	46±1	YES
SFT123	52±3	52±1	YES
PL08	715±30	706 ± 2	YES
PL09	1040±50	1067 ± 2	YES

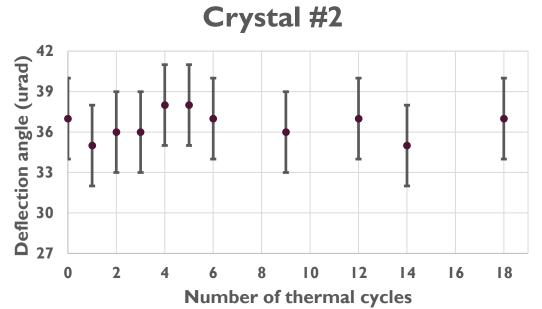


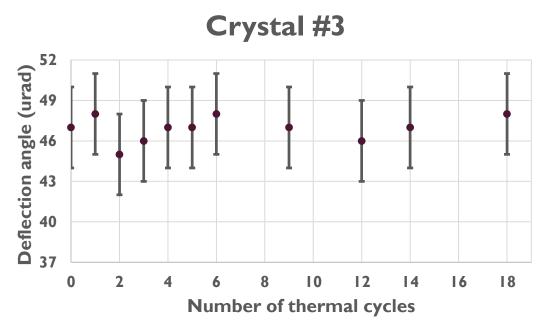
Determinantion of crystal bending angle with high-resolution x-ray diffraction and channeling of high-energy particles are in good agreement.

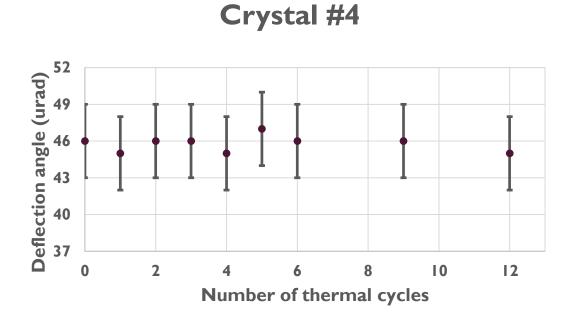
### HOLDERS THERMAL STABILITY

Crystal bending angle is measured through high-resolution x-ray diffraction before and after thermal cycles for 41 holder+crystals assemblies.







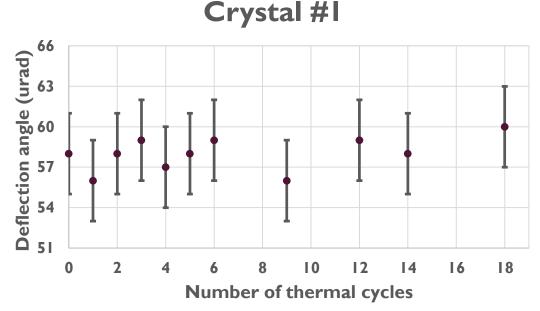


#### HOLDER STABILITY VS BAKE-OUT: CONCLUSIONS

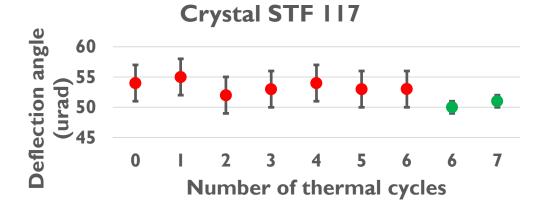
Manufactured 41 holders (31 titanium grade 2+10 titanium grade 5).

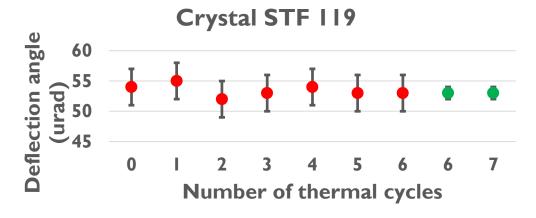
41 holders subjected to bake-out thermal cycles.
 Performed a total of 243 thermal cycles.

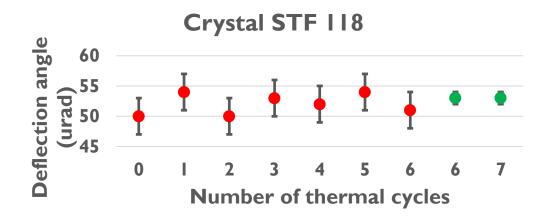
For all the cases crystal bending angle is stable.

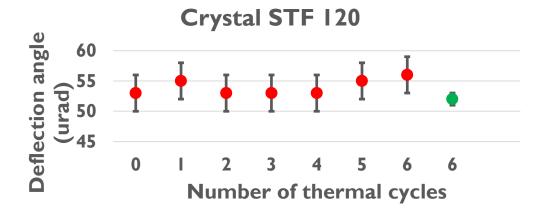


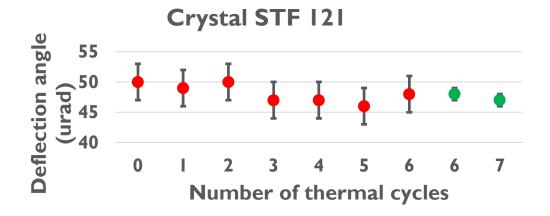
Newly developed holders (both titanium grade 5 and titanium grade 2) are thermally stable with respect to bake-out cycles.

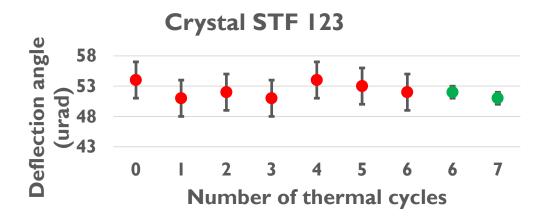


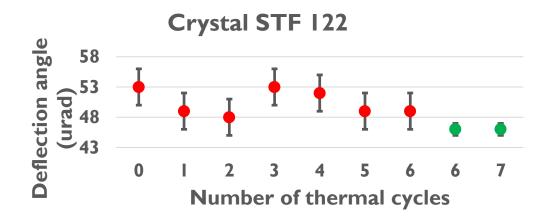


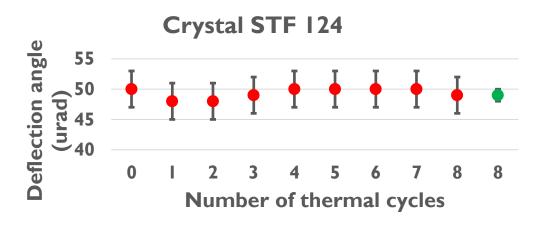


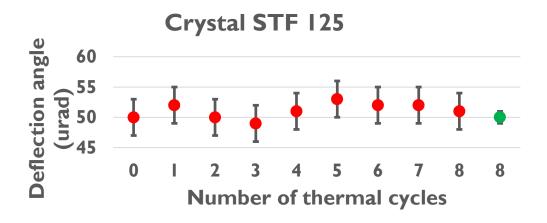


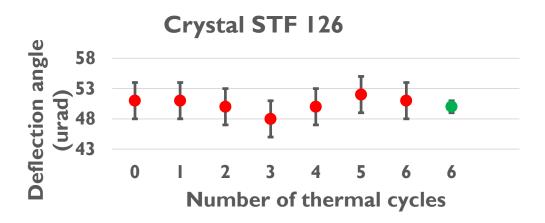












Crystal code	Bending angle	Miscut	Bakeable
STF117	51±1	6±1	YES
STF118	53±1	6±1	YES
STF119	53±1	6±1	YES
STF120	52±1	6±1	YES
STF121	47±1	6±1	YES
STF122	46±1	6±1	YES
STF123	51±1	6±1	YES
STF124	49±1	6±1	YES
STF125	50±1	6±1	YES
STF126	50±1	6±1	YES

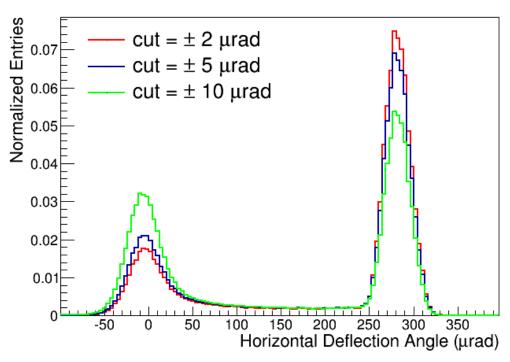


## CRYSBEAM EU PROJECT

Motivation: extraction of the LHC circulating beam, delivering extracted particle beams to users







Deflection ~0.3 mrad

Need of a crystal bent at ~I mrad, bending radius ~80 m

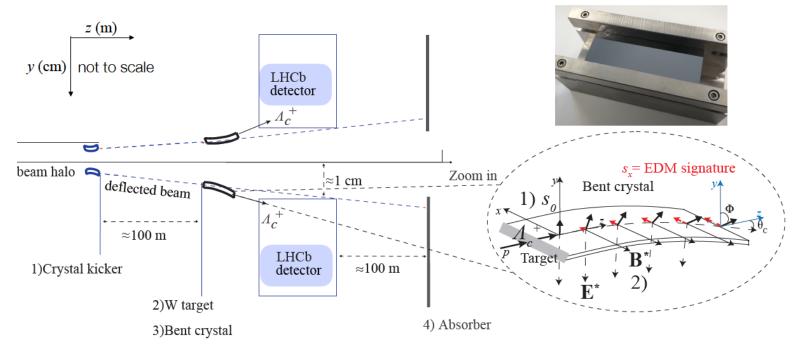
## SELDOM EU PROJECT

**Novel** fixed-target experiment at LHC for charm baryons



P.I. Nicola Neri

▶ EDM/MDM from spin precession of channeled baryons in **bent crystals** 



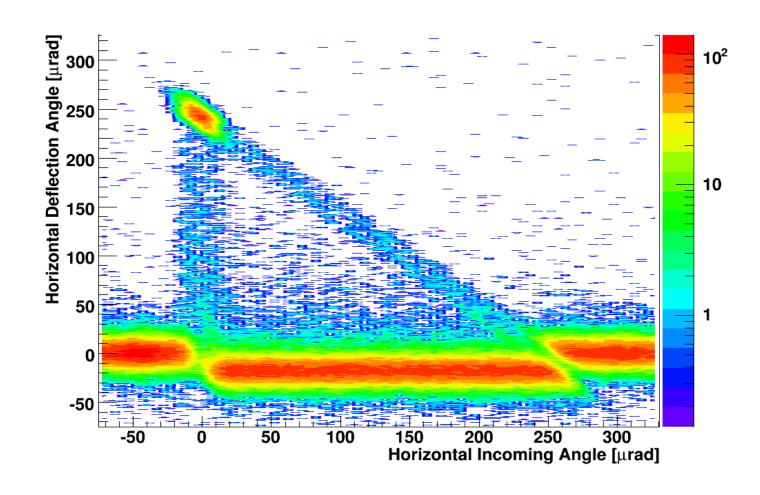
p extraction  $\Lambda_c^+$  polarised production channeling spin precession event reconstruction

## **GERMANIUM CRYSTALS**

 We own the technology to machine also germanium crystals

Mechanical machining

 Chemical etching for lattice damage removal



#### MOST RECENT DEVELOPMENTS

- Crystals with miscut less than I urad
- Assessed a correlation between x-ray and particle measurements
- Thanks to the experience already gained in development of holders for the SPS, pre-shaped holders made of titanium (grade 2/grade 5) are now available
- Holders/crystals assembly are now bakeable to 250 °C
- Tight requirement on bending angle can be routinely satisfied
- Recent progresses on torsion reduction

#### CONCLUSIONS

- INFN owns the expertise, technical resourses, manpower to perform channeling experiments at any wordwide facility.
- Established a protocol for manufacturing of crystals free from crystalline defects.
- Possibility to deliver crystals with miscut lower than I urad.
- Developed a protocol to manufacture crystals matching requirements for installation in the LHC.
- Possibility to realize germanium crystals
- Possibility to realize cm-thick uniformly bent crystals